APPROVE HONORARY DEGREES, 2008, CHICAGO

**Action:** Approve the Award of Honorary Doctorate Degrees for 2008, Chicago

**Funding:** No Funding Required

The Senate at the Chicago campus has nominated the following persons for conferral of honorary degrees at Commencement exercises in May 2008. The Chancellor recommends approval of these nominations.

**Richard Hill,** Influential and innovative world leader of the international semiconductor industry, Chief Executive Officer of Novellus Systems, Inc., and Chairman of the Board of Directors -- the honorary degree of Doctor of Engineering

Mr. Hill has distinguished himself as one of the world’s most influential and innovative leaders of the international semiconductor industry. He has been a pioneer both in broadening the industry’s base of scientific and engineering personnel and in expanding the sphere of science and technology to include more basic underlying elements. He has been a driving force behind many of the innovations needed to transition the multi-billion dollar semiconductor industry from the past technology of micron-sized device features to the vital emerging and future technology of sub-100 nanometer-sized devices. Mr. Hill has been a prominent leader in expanding U.S.-China collaborations with special emphasis on bringing the most knowledgeable members of the Chinese academic community into the international community. His ability to lead the international community in new and vital directions is unparalleled. Mr. Hill is a dedicated champion and tremendous friend to the Chicago campus and its College of Engineering. He is Chairman of the College of Engineering Advisory Board and a Board member of the University of Illinois Foundation. Mr. Hill also serves on the boards of LTX Corporation, Agere Systems, Inc., Semiconductor Equipment and Materials International Association (SEMI), and Arrow Electronics. Richard Hill is an alumnus of the Chicago campus with a Bachelor of Science degree in
Bioengineering and a Master’s degree in Business Administration from Syracuse University.

Walter Netsch, Architectural Designer, Visionary Site Planner and Creator of the University of Illinois at Chicago Circle (UICC) campus -- the honorary degree of Doctor of Architecture

Mr. Netsch was the site planner for the University of Illinois at Chicago Circle (UICC) campus and the designer of most of the UICC campus buildings. Mr. Netsch and his team at Skidmore, Owings & Merrill (SOM) were involved in site selection, schematic design options, and campus master planning. The task involved an intense exploration of new technologies, new ideas about pedagogy and new conceptions about the university and its role in the community. Architectural Forum (September 1965), the country’s premier architectural journal, devoted 25 pages to UICC. Mr. Netsch was a long-time employee and general partner at SOM and one of the most prolific and conspicuous architects of the post World War II era. During his career he designed hundreds of buildings across the United States and elsewhere in the world. His work includes the Inland Steel Building in Chicago, the U.S. Air Force Academy campus in Colorado Springs, the Regenstein Library at the University of Chicago campus, and the main library building for Northwestern University in Evanston. Mr. Netsch played a considerable role in Chicago area civic life, including service on the Film Center Advisory Board of the Art Institute of Chicago, the Landmarks Preservation Council, Board of Directors of the Metropolitan Housing and Planning Council of Chicago, and Trustee of the Museum of Contemporary Art, to name a few. He was also president of the Chicago Park District during the administration of Harold Washington. Mr. Netsch received his Bachelor of Architecture from the Massachusetts Institute of Technology.

The Board action recommended in this item complies in all material respects with applicable State and federal laws, University of Illinois Statutes, The General Rules Concerning University Organization and Procedure, and Board of Trustees policies and directives.

The President of the University concurs.